



FORM PTO-1449 U.S. Department of Commerce Patent & Trademark Office	Attorney Docket No. 038788.52799US	Serial No. 10/670,744
	Applicant: Satoru KOBAYASHI, et al.	
	Filing Date: September 26, 2003	Group:

**INFORMATION DISCLOSURE STATEMENT**  
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U.S. PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Name	Class	Sub-Class	Filing Date (if appropriate)
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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)							
	AQ	Kamon, et al., "Newly Developed Acrylic Copolymers for ArF Photoresist", <i>Journal of Photopolymer Science and Technology</i> , Vol. 15, No. 4 (2002), pp. 535-540					
	AR						
	AS						

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